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Electrical conductive double-walled carbon nanotubes – Silica glass nanocomposites prepared by the sol-gel process and spark plasma sintering

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The electrical conductivity of suspensions in liquid of several kinds of carbon nanotubes (CNTs) is measured. Raw and soft-functionalized double-walled carbon nanotubes (DWCNTs) appear to be the most promising for achieving a low electrical percolation threshold. A 0.35 vol.% DWCNTs–SiO₂ nanocomposite is prepared by the sol–gel process and densified by spark plasma sintering. The obtained material presents a fairly good dispersion of DWCNTs and its electrical conductivity $(10^{-4} \text{ S cm}^{-1})$ is six orders of magnitude higher than that previously reported for 1 vol.% multi-walled CNTs–SiO₂.

Keywords: Carbon nanotubes; Nanocomposites; Silica; Spark plasma sintering; Electrical conductivity

The outstanding electrical, thermal and mechanical properties of carbon nanotubes (CNTs) have broadened the research into nanocomposites [1]. In ceramic matrices, the addition of CNTs can not only improve mechanical properties, but also give rise to electrical percolation in an insulating matrix at a much lower content (<1 vol.%) than any other additives due to their huge aspect ratio (1000-10,000) [2]. However, the main challenges remain the dispersion of CNTs into the matrix and the densification of the material [1,2]. To overcome the first difficulty, CNTs can either be synthesized in situ in the ceramic powder or the ceramic precursor can be synthesized around CNTs dispersed in a solvent (with the aid of chemical functionalization or the use of surfactants, followed by sonication) [1,2]. To sinter the materials, spark plasma sintering (SPS) is preferred to hot-pressing (HP) because it allows densification at lower temperature and shorter times, thus limiting the damage to the CNTs [2].

Due to the predicted good chemical interaction of CNTs with silica matrix without altering their original

properties [3,4], CNTs-SiO₂ composites have many potential applications including optical materials [5,6] or opto-electronic devices, as well as electromagnetic interference shielding devices [7,8]. Since the precursor work of Gavalas et al. [9] on CNTs-silica xerogel composites, there have been several reports on CNTs-SiO₂ densified composites [5-7,10-12]. Different types of CNTs, dispersion methods and densification techniques have been used to prepare these composites. In most cases [7,8,10–12], multi-walled CNTs (MWCNTs) were preferably used probably due to their higher disponibility and lower costs in comparison to single-walled (SWCNTs) or double-walled CNTs (DWCNTs). Despite SWCNTs allowing percolation to be achieved with a lower load than MWCNTs, few studies have been dedicated to SWCNTs-SiO₂ composites [5,6]. Their functionalization would induce damage to their only wall, compromising their electronic properties. In this context, DWCNTs have recently gained special attention since functionalization can occur on the outer wall without damaging the electronic properties from its inner tube [13].

The large surface area and high aspect ratio of CNTs associated with their high hydrophobicity makes it difficult to properly disperse them in any medium at the

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concentrations required for their application in composites. Therefore, various approaches to improving the dispersion of CNTs into SiO₂ have already been tested in terms of modification of the interface (by use of surfactants [5,7,8,10,11] and chemical functionalization [6]), as well as methods of composite preparation (attrition mill with colloidal SiO₂ [12] or in situ production of silica by organic [6–8,10,11] or inorganic [5] sol–gel routes). In addition, the incorporation of CNTs into silica glass is detrimental to densification because it slows the sintering kinetics, as any fiber does in a glass matrix [14]. Consequently, several techniques have also been tested to densify these composites, including heat treatment in an inert atmosphere [5], HP [7,8,10,11], high-pressure cold quasi-isostatic pressing [6] and SPS [12].

In terms of electrical conductivity, the lowest loading exhibiting percolation that has been reported was 1 vol.% for MWCNTs–SiO₂ composites [9], which achieved an electrical conductivity of about 10^{-10} S cm⁻¹. A higher CNTs content results in a higher conductivity. For example, 0.08 and 0.65 S cm⁻¹ were measured for 5 and 10 vol.% MWCNTs–SiO₂, respectively [12], while 0.15 S cm⁻¹ was achieved with 4 wt.% of functionalized SWCNTs [5].

The aim of this work was to prepare an electrically conductive CNTs-SiO₂ composite with a much lower CNT content by properly selecting the appropriate CNTs, optimizing a method to achieve a good dispersion and using SPS to obtain a high densification without damaging the CNTs. DWCNTs (89.2 wt.% C) produced by catalytic chemical vapour deposition [15] were acid-functionalized (using nitric, sulphuric and chloridric acids at room temperature) [16]. Briefly, the DWCNTs were submitted to a soft functionalization that consists of adding them to a mixture of nitric and sulphuric acids and submitting the mixture to bath sonication for about 1 h, followed by 24 h of stirring. After that, chloridric acid was added and the mixture was stirred for 10 min. Finally, the acids were neutralized by the addition of ammonia solution followed by filtration and rinsing with deionized water. Functionalized DWCNTs (f-DWCNTs) were characterized by comparing the Raman spectra (1.96 eV, Jobin-Yvon LabRam) of the



Figure 1. Raman spectra of the DWCNTs (a), f-DWCNTs (b) and f-DWCNTs–SiO₂ composite after SPS at 1000 $^{\circ}$ C (c).

DWCNTs and f-DWCNTs. The spectra (Fig. 1a and b) were normalized to the G-band (ca. 1586 cm⁻¹). Raman breathing mode (RBM) peaks (ca. 156, 214 and 255 cm⁻¹) were observed for both samples. The ratio between the intensities of the D-band (ca. 1327 cm⁻¹) and the G-band, $I_{D/G}$, is higher for f-DWCNTs than for DWCNTs (0.2 and 0.1, respectively) due to the opening of the C–C bonds by functionalization [17]. A downshift (~2 cm⁻¹) of the G-band, the graphene dominant tangential mode and an upshift (~2 cm⁻¹) of the D* band (originally ca. 2616 cm⁻¹) were observed after DWCNTs were functionalized, probably reflecting a charge transfer caused by the chemical oxidation [13].

The electrical conductivity in dynamic mode [18] for DWCNTs and f-DWCNTs suspensions in liquid chloroform was measured (Fig. 2) in order to check the effect of the chemical oxidation. A two-probe cell configuration was used (the immersed 15.5×5.2 mm electrodes were 5 mm apart) with continuous probe ultrasonication (probe diameter of 2.5 mm) using a GW Instek GPS-18300 DC power supply and a Philips PM2525 apparatus. The measures were made for progressively increasing CNTs contents. For the maximum f-DWCNTs content (0.28 vol.%) in liquid chloroform, the conductivity was ca. 6.10^{-3} S cm⁻¹ (about three times lower than for DWCNTs). However, for lower f-DWCNTs contents, the difference decreases and even disappears, indicating that the oxidation has not severely damaged the f-DWCNTs. Commercial DWCNTs (Nanocyl, 90 wt.% C) were tested as well and always showed a lower conductivity. In comparison to previous results with commercial (HipCO, 81.3 wt.% C) SWCNTs [18], at higher CNTs contents, the conductivity was similar to or slightly higher than that for DWCNTs. However, for lower CNTs contents, the conductivity of SWCNTs decreased sharply (by far the lowest of all tested materials), reflecting their lower aspect ratio [18]. Considering that these CNT dynamic dispersions in chloroform are optimal [18], these results shows that the DWCNTs and the f-DWCNTS used in the present study are better suited to obtain the electrical percolation in the SiO_2 matrix than the other tested CNTs. Only f-DWCNTs will be considered for the rest of the study because



Figure 2. Conductivity in dynamic state for chloroform suspensions of DWCNTs, f-DWCNTs and commercial SWCNTs [18] and DWCNTs.

functionalization is essential for developing a good dispersion in the matrix.

A nitric acid aqueous solution containing f-DWCNTs was prepared with the aid of probe sonication (Bioblock Scientific Vibracell 75042). This suspension was poured into an alcoholic solution containing tetraethylorthosilicate (TEOS) as silica precursor, sonicated for 1 min and then left to gelify at room temperature for several days with stirring. For comparative purposes, a product without CNTs was prepared by the same route. The molar ratio of water to TEOS was 20 for the composite and 4.5 for pure silica. The xerogels were ground and calcinated in air at 400 °C. The carbon content in the thusobtained composite powder was 0.29 wt.% (i.e. ca. 0.35 vol.% f-DWCNTs, taking 1.80 g cm^{-3} for the f-DWCNTS). The powders were densified by SPS (Dr. Sinter 2080, SPS Syntex Inc. at the Plateforme Nationale CNRS de Frittage-Flash – PNF2, Toulouse) using a 20 mm diameter graphite die (1000 °C, 5 min dwell time, 50 MPa). The density measured by Archimedes' method was found to be 2.134 and 2.112 $g cm^{-3}$ for SiO₂ and f-DWCNTs-SiO₂, respectively. These values correspond to relative densities of ca. 97% and 96%, respectively, using 2.20 g cm^{-3} for SiO₂ [19] and 1.80 g cm^{-3} for the DWCNTs. X-ray diffraction (XRD: Bruker D4 Endeavor) pattern analysis (Fig. 3) revealed that pure SiO₂ was still amorphous, whereas a peak was observed for the composite, showing the beginning of crystallization. These observations are in good agreement with other works [11] and suggest that CNTs might act as germs for the heterogeneous nucleation of crystalline SiO₂ [20]. Moreover, one should not forget the possible effect of residual water since the large surface area of the DWCNTs might make complete outgassing difficult during the calcination and densification steps.

The Raman spectrum for the densified f-DWCNTs– SiO₂ nanocomposite (Fig. 1c) is dominated by the fluorescence of silica, thus masking many features corresponding to the CNTs. Nevertheless, the most intense RBM peak observed for f-DWCNTs (Fig. 1b) is still detected and there is no obvious increase in the D band intensity, which could reflect that the DWCNTs were not grossly damaged by SPS. The frequency of the Gband (1591 cm⁻¹) is upshifted (~ 5 cm⁻¹) compared to



Figure 3. XRD patterns of the SiO₂ and f-DWCNTs–SiO₂ materials consolidated by SPS.

f-DWCNTs. Puech et al. [21] showed through in situ Raman spectroscopy of DWCNTs in a diamond anvil cell that there is a linear dependence between the shift in the frequency of the G-band and the applied isostatic pressure up to 12 GPa. Thus, these results could suggest that the f-DWCNTs remain under residual pressure in the matrix, which could also reflect the good interaction between the SiO₂ and CNTs mentioned in other studies [3,4]. A G-band upshift was also reported for f-SWCNTs–SiO₂ composites [6]. Moreover, the D* band upshift of ~6 cm⁻¹ (from 2616 to 2622 cm⁻¹) also suggests a good interaction.

Field emission gun-scanning electron microscopy (FESEM; JEOL JSM 6700F, at TEMSCAN, Université Paul-Sabatier) observations of the fracture surface of the composite (Fig. 4a) revealed the good dispersion of the f-DWCNTs in the matrix. However, the observation of a few agglomerates and some areas apparently without any f-DWCNTs indicated that it was still not optimal. Good wetting of the f-DWCNTs by the matrix was achieved, as shown in Figure 4b, with CNTs protruding out of an SiO₂ grain (confirming our Raman spectroscopy results and predictions [3,4]).

The densified samples were cut and polished into bars $\sim 10 \text{ mm} \log (\sim 2 \text{ mm} \times 2 \text{ mm} \text{ in section})$ and metallized on the two square faces by a silver paste. The electrical conductivity of the f-DWCNTs-SiO₂ nanocomposite was measured on six bars (Philips PM2525 apparatus). The average electrical conductivity was $(1.0 \pm 0.1) \times 10^{-4} \text{ S cm}^{-1}$. This value is lower than that obtained in liquid $(6 \times 10^{-3} \text{ S cm}^{-1} \text{ for } 0.28 \text{ vol.}\%$ f-DWCNTs, Fig. 2), probably due to the better dispersion of f-DWCNTs in the chloroform suspension with constant sonication than in the composite (even more so as the CNTs were dispersed in acidic medium [22]). However, the obtained value is six orders of magnitude higher than that reported by Xiang et al. [10] for 1 vol.% MWCNTs-SiO₂ and might possibly still be increased, for the same CNTs content, with a better dispersion, thus creating more possibilities of conduction paths.

In conclusion, we prepared an electrical conductive CNTs–SiO₂ composite with a very low CNT content. Measurements of the electrical conductivity of CNT



Figure 4. FESEM images of the fracture surface of the 0.35 vol.% f-DWCNTs–SiO₂ nanocomposite.

suspensions in liquid showed that the present DWCNTs, pristine or functionalized, are better suited to obtaining the electrical percolation at a low content compared to commercial SWCNTs or DWCNTs. The soft functionalization by chemical oxidation at room temperature did not cause any gross damage. A 0.35 vol.% f-DWCNTs-SiO₂ nanocomposite was prepared by the sol-gel process and sintered by SPS. The f-DWCNTs were fairly well dispersed, although it could still be improved, and a good interaction with SiO₂ was evidenced. The electrical conductivity (ca. $10^{-4} \,\mathrm{S \, cm^{-1}}$) is six orders of magnitude higher than that reported [10] for 1 vol.% MWCNTs-SiO₂. Furthermore, if further works are needed to obtain transparent materials by avoiding the presence of remaining pores, the achieved electrical conductivity for this composite is high enough to antielectrostatic [23] or heating elements [24].

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